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Docket No.: HOK-0255
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Akira TSUJIMOTO et al.

Application No.: 10/522,014

Confirmation No.: 2048

Filed: August 4, 2005

Art Unit: 1712

For: PHOTOCATALYST-CONTAINING SILICONE
RESIN COMPOSITION AND COATED ARTICLE
WITH CURED FILM OF THE SAME
COMPOSITION

Examiner: MOORE, MARGARET G

STATUS INQUIRY

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

It is respectfully requested that the attorney named below be advised of the status of the above-identified application. Please advise us of when we might expect to receive an Office Action from the Patent and Trademark Office.

Applicant believes no fee is due with this response. However, if a fee is due, please charge our Deposit Account No. 18-0013, under Order No. HOK-0255 from which the undersigned is authorized to draw.

Dated: November 16, 2006

Respectfully submitted,

By 

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